

Supporting Information

Synthesis and Solution Self-Assembly of Block Copolymers with a Gradient, Crystallizable Polyferrocenylsilane Core-Forming Metalloblock

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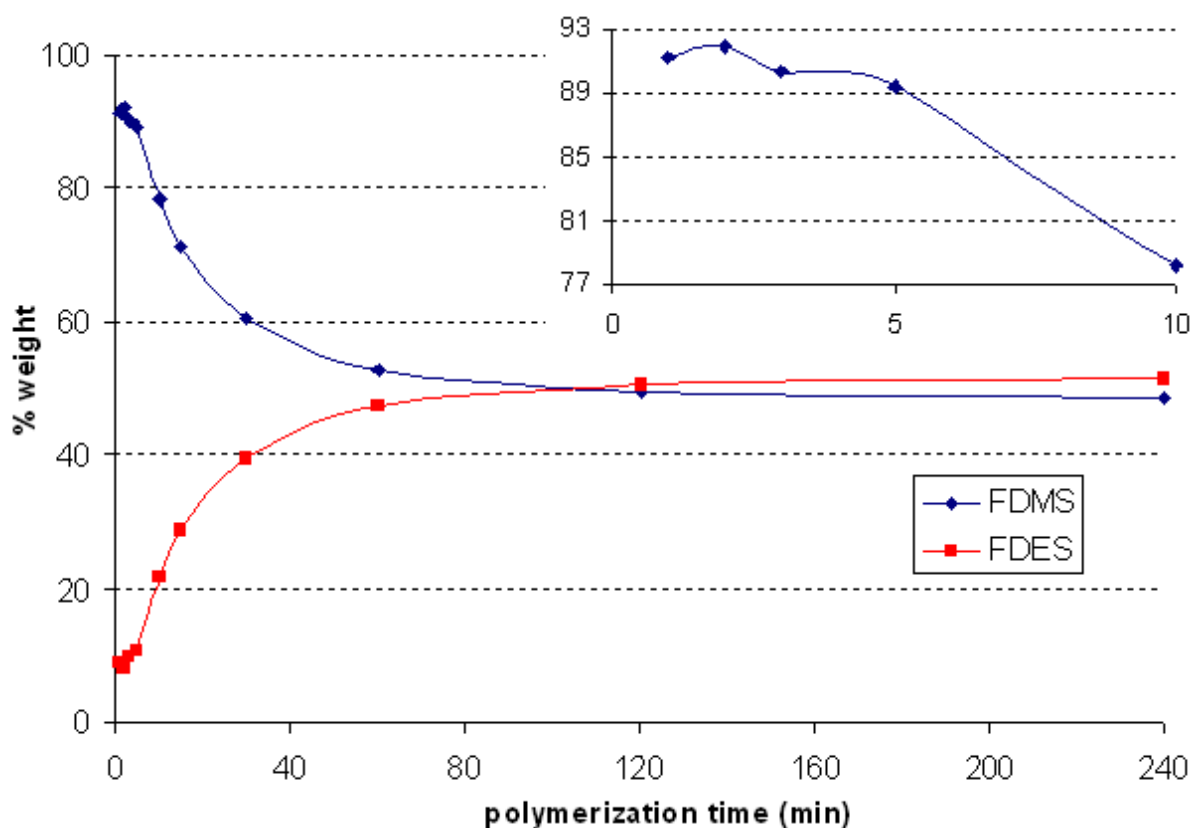


Fig. S1 Monomer weight percentage in the gradient copolymer through the course of polymerization (see Table 2).

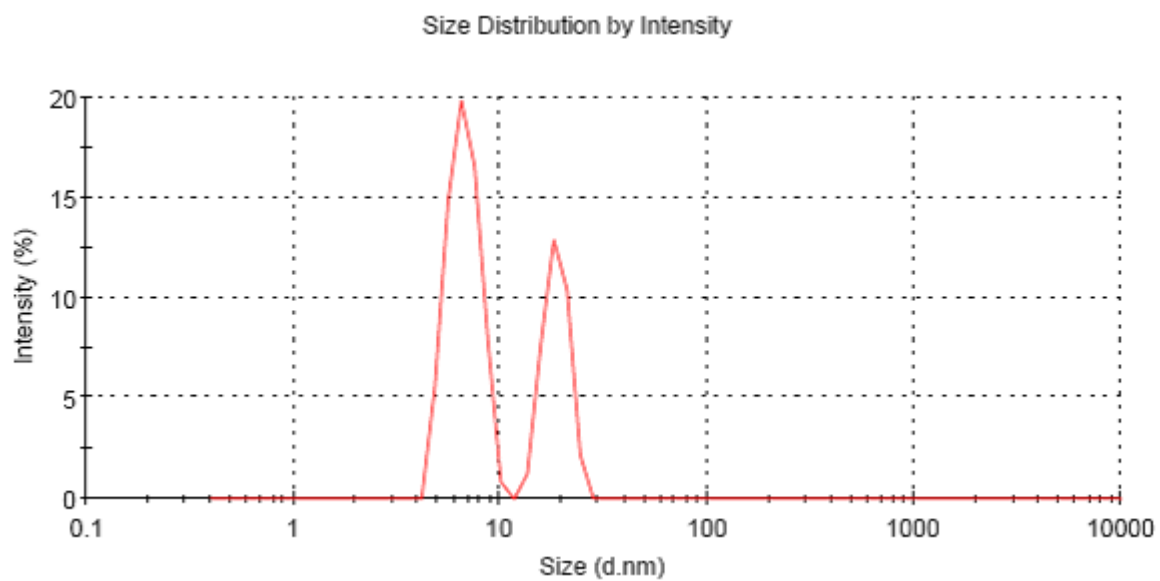


Fig. S2 DLS data for $PI_{387}\text{-}b\text{-(PFDMS}_{22}\text{-grad-PFDES}_{17})_{39}$ micelles described in Figure 4A.